

Mark Name	TM Application Status	Country
300WORKS	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United Kingdom
		United States of America
		A (stylized)
		Benelux
		Brazil
		Canada
		China
		European Union
		France
		Germany (Federal Republic of)
		Hong Kong
		India
		Indonesia
		Ireland (Republic of)
		Israel
		Italy
		Japan
		Korea, Republic of (KR)
		Malaysia
		Mexico
		Philippines
		Russian Federation
		Singapore

A (stylized)	Registered	Spain Sweden Switzerland Taiwan Thailand United Arab Emirates United Kingdom United States of America
A (stylized) (with Cropped Banner Device)	Registered	China
A APPLIED MATERIALS (stylized in centered presentation)	Registered	China
A APPLIED MATERIALS (stylized)	Registered	China Thailand United States of America
A APPLIED MATERIALS MAKE POSSIBLE (stylized)	Registered	Taiwan
ACCESS	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
ACENTA	Allowed Application Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
ACTIVITY MANAGER	Application Registered	China International

ACTIVITY MANAGER	Registered	Japan Korea, Republic of (KR) United States of America
Acuity	Application Registered	Korea, Republic of (KR) China European Union International Japan Singapore United States of America
ADEN	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
ADVENT	Registered	Taiwan
AdvisorMV	Registered	European Union United Kingdom
AERA	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore United States of America
AERIS	Application Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AF-Mag	Registered	Benelux China

AF-Mag

Registered

Czechia
Finland
France
Germany (Federal Republic of)
Hungary
India
International
Italy
Japan
Korea, Republic of (KR)
Liechtenstein
Poland
Portugal
Spain
Sweden
Switzerland
Taiwan
Turkey
United Kingdom

Agile ALD

Application

China
India

Registered

Canada
European Union
International
Japan
Korea, Republic of (KR)
Russian Federation
Singapore
Switzerland
Taiwan
United Kingdom

AI Design Forum

Registered

United States of America
United States of America

AI OLED

Application

China

AI OLED

Application

European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

AI(X)

**Allowed
Application
Registered**

United States of America
China
European Union
International
Israel
Japan
Singapore
Taiwan

AIDF

**Registered
Registered**

AITHION

United States of America
Australia
Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom

AIX

**Allowed
Application
Registered**

United States of America
China
European Union
International

AIX	Registered	Israel Japan Korea, Republic of (KR) Singapore Taiwan
AJAX	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
AKT	Application	China International
	Registered	China Germany (Federal Republic of) Ireland (Republic of) Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AKTIV	Application	China
	Registered	United States of America
ALPS	Registered	United States of America
ALTA	Registered	France Germany (Federal Republic of) United States of America
Alteza	Application	China European Union Israel Japan Korea, Republic of (KR)

Alteza	Application	Singapore Taiwan United States of America
ALTUM	Registered Registered	International Australia Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom United States of America
AMAT	Registered	Benelux
APF	Registered	United States of America
APF FUSION	Registered	United States of America
APF RTD	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APOLLO	Allowed Published Registered	Taiwan Korea, Republic of (KR) Japan United States of America

APPLIED	Registered	Benelux Japan
APPLIED AERIS	Registered	China
APPLIED AERIS-G	Published	China
Applied AI(X)	Registered	China
APPLIED CHARGER	Allowed	United States of America
APPLIED E3	Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APPLIED ENDURA IMPULSE	Application Registered	United States of America Japan Korea, Republic of (KR) Taiwan
APPLIED FABVANTAGE	Registered	United States of America
Applied Forecast Parts Management	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
APPLIED GLOBAL SERVICES	Registered	United States of America
Applied Inside OLED	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America

Applied Inside OLED
Applied Managed Service

Registered
Registered

International
International
Japan
Taiwan
United States of America

APPLIED MATERIALS

Registered

Australia
Benelux
Brazil
Canada
China
European Union
France
Germany (Federal Republic of)
Hong Kong
India
Indonesia
International
Ireland (Republic of)
Israel
Italy
Japan
Korea, Republic of (KR)
Malaysia
Mexico
Philippines
Russian Federation
Singapore
Spain
Sweden
Switzerland
Taiwan
United Arab Emirates
United Kingdom
United States of America

APPLIED MATERIALS A (stylized) (with Blue Banner Device)	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters (with Rounded Rectangle Device)	Registered	China
APPLIED MATERIALS and Japanese Characters	Registered	Japan
APPLIED MATERIALS, INC	Registered	China
APPLIED MOSAIC	Application	United States of America
Applied Nanophotonics	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APPLIED OLYMPIA	Registered	International
APPLIED OLYMPIA ALD	Registered	Japan
Applied OnDemand	Registered	Japan
	Application	China
	Registered	International Japan Taiwan United States of America
APPLIED OPUS	Registered	United States of America
APPLIED PERFORMANCE SERVICE	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
APPLIED SANSA	Registered	China
APPLIED SMARTFACTORY	Registered	European Union International Japan Singapore

APPLIED SMARTFACTORY	Registered	Taiwan United Kingdom United States of America
APPLIED SMARTFACTORY RX	Registered	China Taiwan
APPLIED SPRINTER	Published	China
APPLIED THERMION	Registered	Japan Taiwan
APPLIED VENTURES	Registered	United States of America
AppliedAI(X) (stylized with superscript)	Allowed Application Registered	United States of America Malaysia Canada European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom
appliedmaterials.tw	Registered	Taiwan
AppliedPRO	Application Registered	Canada European Union Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Canada European Union International Israel

AppliedPRO	Registered	Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United States of America
AppliedTwin	Application	China Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore Taiwan
ARAGON	Allowed Registered	United States of America China International Japan Korea, Republic of (KR) Singapore Taiwan
arCADe	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan
ArchitectMV	Published Registered Registered	United States of America International United Kingdom
Arian	Application	Israel Japan

Arian	Application Published	Korea, Republic of (KR) Singapore United States of America
	Registered	European Union International
ARISTO	Registered	Germany (Federal Republic of)
ARNO	Allowed	United States of America
	Registered	China International Japan Korea, Republic of (KR) Singapore Taiwan
AthenaAI	Registered	European Union International Israel Japan Singapore United States of America
AUTOMOD	Published	China
	Registered	European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AUTOSCHED	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan

AUTOSCHED	Registered	United Kingdom United States of America
AVATAR	Registered	China United States of America
AVENIR	Registered	United States of America
AVILA	Allowed	United States of America
AVINA	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AXCELA	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
	Published	United States of America
	Registered	China European Union Singapore
AXIOM	Registered	United States of America
B (stylized)	Registered	Australia Belarus China Croatia European Union Hong Kong India International Italy Japan

B (stylized)

Registered

Korea, Republic of (KR)
Norway
Russian Federation
Serbia
Singapore
Switzerland
Taiwan
Turkey
Ukraine
United Kingdom
United States of America
Vietnam

BACCINI (stylized)

Registered

Australia
Belarus
China
Croatia
European Union
Hong Kong
India
International
Italy
Japan
Korea, Republic of (KR)
Norway
Russian Federation
Serbia
Singapore
Switzerland
Taiwan
Turkey
Ukraine
United Kingdom
United States of America
Vietnam

BatchMV	Registered	United Kingdom
BioAPC	Allowed	United States of America
	Registered	Singapore
		United Kingdom
BioMV	Registered	United Kingdom
BIONEURON	Registered	United Kingdom
BLACK DIAMOND	Registered	Japan
		United States of America
BLACKHAWK	Registered	China
		Korea, Republic of (KR)
		Taiwan
		United States of America
BLACKSTONE	Registered	China
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United States of America
BLAZER	Registered	United States of America
CARINA	Registered	United States of America
CATALYST	Allowed	United States of America
	Application	China
		Japan
		Korea, Republic of (KR)
		Singapore
	Registered	European Union
		International
CELLWORKS	Registered	Singapore
		United Kingdom
		United States of America
CENTINEL	Registered	United States of America
CENTRIS	Registered	China
		United States of America
CENTURA	Registered	Benelux

CENTURA

Registered

China
European Union
France
Germany (Federal Republic of)
Hong Kong
India
Indonesia
Ireland (Republic of)
Israel
Italy
Japan
Korea, Republic of (KR)
Singapore
Spain
Sweden
Switzerland
Taiwan
United Kingdom
United States of America

CENTURA (and Katakana version)

Registered

CENTURA WXP

Registered

Singapore
Taiwan

ChamberAI

Application

Registered

China
Canada
European Union
International
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United States of America

ChamberTwin

Application

China

ChamberTwin	Application	Japan Korea, Republic of (KR) United States of America
	Registered	European Union International Singapore Taiwan
Ciena	Registered	United States of America
CLARA	Application	China Korea, Republic of (KR)
	Registered	International
CLARION	Registered	China European Union International Korea, Republic of (KR) Singapore Taiwan United States of America
CLARIPHI	Allowed	Japan
	Registered	China Korea, Republic of (KR) Taiwan
		United States of America
CLASS MCS 5	Application	Malaysia
	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
		United States of America
CLEAN MODE	Registered	United Kingdom
CLEANCOAT	Registered	International

CLEANCOAT

Registered

Japan
Korea, Republic of (KR)
Taiwan

CLERE

**Allowed
Registered**

United States of America
United States of America
Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Taiwan

CloudSim

**Allowed
Application**

United States of America
Japan
Korea, Republic of (KR)

Registered

European Union
International
Singapore
Taiwan

CLOVER

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom

ComPLUS

Application

United States of America
China
European Union
International
Israel

ComPLUS	Application	Japan Korea, Republic of (KR) Singapore Taiwan United States of America
CONFORMA	Registered	Taiwan
Contorno	Application Published	Korea, Republic of (KR) Israel United States of America
	Registered	China European Union International Japan Singapore Taiwan
Contour	Allowed	United States of America
ControlMV	Registered	United Kingdom
CORNERSTONE	Registered	United Kingdom
CORONA UV	Registered	Korea, Republic of (KR) Taiwan
CORSA	Application Registered	International Australia Canada China European Union Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
CRION	Registered	United States of America

CrossMatch Cupryx	Registered Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
DARC	Registered	United States of America Korea, Republic of (KR) Taiwan
DESICA DeviceTwin	Registered Application	United States of America United States of America China Korea, Republic of (KR) Singapore United States of America
Digital Dynamic Connection	Registered Application	International Japan China Korea, Republic of (KR) United States of America
DIMENSION	Registered	European Union International Japan Singapore China France Germany (Federal Republic of) International Israel Japan Korea, Republic of (KR) Singapore

DIMENSION	Registered	Taiwan United Kingdom United States of America
DLT	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
DMO SYSTEMS	Registered	International
DPS	Registered	Taiwan
	Registered	China European Union Korea, Republic of (KR) Singapore United Kingdom United States of America
DPS CENTURA	Registered	Benelux France Germany (Federal Republic of) Hong Kong Indonesia Ireland (Republic of) Italy Japan Korea, Republic of (KR) Singapore Spain Sweden Taiwan United Kingdom United States of America

DRACO	Application Registered	China International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
DROSSA	Registered	China International Japan Korea, Republic of (KR) Taiwan
DSF	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
DSFm	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
DURASOURCE	Registered Registered	International United States of America
DURUM	Registered	China European Union International Japan Korea, Republic of (KR)

DURUM	Registered	Malaysia Singapore Taiwan United States of America
EcoTwin	Application Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ecoUP	Application	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
EduTwin	Published Registered Allowed Application Registered	United Kingdom International United States of America Korea, Republic of (KR) European Union International Israel Japan Singapore Taiwan
Elevated Materials	Allowed Application	United States of America Korea, Republic of (KR)

Elevated Materials

**Application
Registered**

Taiwan
China
European Union
International
Japan

ELI

**Allowed
Application**

United States of America
China
Korea, Republic of (KR)
Taiwan

Registered

European Union
International
Japan
Singapore

ELUMINATOR

Application

China
Korea, Republic of (KR)
Taiwan

Registered

European Union
International
Japan
United Kingdom
United States of America

EMAX

Registered

United States of America

ENDURA

Registered

Benelux
China
European Union
France
Germany (Federal Republic of)
Hong Kong
India
Indonesia
Ireland (Republic of)
Israel
Italy
Japan

ENDURA	Registered	Korea, Republic of (KR) Singapore Spain Sweden Switzerland Taiwan United Kingdom United States of America
ENDURA CIRRUS	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
ENDURA IMPULSE	Allowed Registered	United States of America China
ENFLEXOR	Registered	United States of America
ENGINEEREDWORKS	Application Registered	International European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
EngineeringTwin	Application Registered	United States of America Korea, Republic of (KR) United States of America European Union International Japan
ENLIGHT	Application	Singapore China

ENLIGHT	Application	Israel Japan Korea, Republic of (KR) Taiwan
ENZO	Registered	European Union Singapore United States of America
EPIC	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
Epic Center	Application	China Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ESATTO AOI	Published Registered Application	European Union International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ESATTO HP kit	Registered Registered	International China Taiwan
	Registered	China

ESATTO HP kit	Registered	Taiwan
ESATTO HP+	Registered	China
ESATTO SEm	Registered	Taiwan China
ESATTO TECHNOLOGY	Registered	Taiwan China Korea, Republic of (KR) United States of America
ESCOSYS	Registered	Austria Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Switzerland United Kingdom
ETERNA	Application	Korea, Republic of (KR)
	Registered	Taiwan China
ETERNA FCVD	Registered	United States of America Taiwan
ETERNA TRINITY	Registered	United States of America
EVEREST	Application	United States of America China Israel Japan Korea, Republic of (KR) Taiwan
	Registered	United States of America European Union International

EVEREST	Registered	Singapore
EXECTA	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
EXPRESS EXCHANGE	Registered	United States of America
ExtractAI	Allowed Application	United States of America China European Union Israel Japan Korea, Republic of (KR) Singapore
	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore
EYED	Registered	United States of America
FAB300	Registered	Australia Benelux France Germany (Federal Republic of) Israel United States of America
FabOptimizer	Registered	United States of America
FACTORYWORKS	Registered	China European Union International Japan

FACTORYWORKS	Registered	Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
FCVD	Registered	China International Japan Korea, Republic of (KR) Malaysia Taiwan United States of America
FERMI	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
FINE LINE DOUBLE PRINTING	Registered	United States of America
FLDP	Registered	China Korea, Republic of (KR) Taiwan United States of America
FLDP (Chinese Characters)	Registered	China Taiwan
FLDP (in simplified Chinese characters)	Registered	China
FleetTwin	Application	China Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore Taiwan
Forma	Allowed	United States of America

Forma	Application	China Israel Korea, Republic of (KR) Taiwan
	Registered	European Union International Japan Singapore
FormulateAPC	Registered	United Kingdom
FormulateMV	Registered	United Kingdom
Fortis	Allowed Application	United States of America China Japan
	Registered	European Union International Korea, Republic of (KR) Singapore Taiwan
Forza	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
	Registered	International
FULLVISION	Registered	United States of America
GARNET	Allowed	United States of America
	Registered	Korea, Republic of (KR)
GEBI	Registered	Canada China European Union International Israel

GEBI

Registered

Japan
Korea, Republic of (KR)
Singapore
Switzerland
United Kingdom
United States of America

GINESTRA

Registered

Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom
United States of America

GUARDIAN

Registered

United States of America

HARP

Registered

China
International
Japan
Korea, Republic of (KR)
Taiwan

HawkEye

**Allowed
Registered**

United States of America
United States of America
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan

HEADSMART

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Taiwan
United Kingdom
United States of America

HIRES

Registered

China
Germany (Federal Republic of)
India
International
Italy
Japan
Korea, Republic of (KR)
United States of America

HydroClean

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom
United States of America

HydroCoat

Registered

European Union
International
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom

HyperSense

Allowed

United States of America
United States of America

HyperSense	Application Registered	Israel European Union International Japan Korea, Republic of (KR) Singapore Taiwan
IC^N	Application Registered	United States of America
ICT	Registered	Germany (Federal Republic of)
ICT (and Design)	Registered	Germany (Federal Republic of) United Kingdom United States of America
IMAP	Registered	United States of America
IMPULSE	Registered	China European Union Korea, Republic of (KR) Taiwan United Kingdom
IMS	Application	China Israel Japan Korea, Republic of (KR) Taiwan United States of America
	Registered	European Union International Singapore
Indigo	Application	China Japan Korea, Republic of (KR) United States of America
	Registered	European Union International Singapore

Indigo Insepra	Registered Allowed Application Registered	Taiwan United States of America Korea, Republic of (KR) China European Union International Japan Singapore
INSTAVISION	Registered	Taiwan China International Korea, Republic of (KR) Singapore
INTEGRATED MATERIALS SOLUTION	Application Registered	United States of America Korea, Republic of (KR) International Japan
Intenza	Allowed Registered	United States of America United States of America China European Union International Japan Korea, Republic of (KR) Singapore
INVIA	Application Registered	Taiwan China Japan European Union Korea, Republic of (KR) Taiwan United Kingdom United States of America

IONIQ

**Application
Registered**

Singapore
China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United Kingdom
United States of America

IRIS

**Application
Registered**

European Union
Japan
Korea, Republic of (KR)
International
Singapore
United States of America

ISANI

Registered

United States of America

ISCAN

Registered

United States of America

ISYSTEM

**Application
Registered**

European Union
China
International
Japan
Korea, Republic of (KR)
Taiwan
United States of America

iSystem Foresight

**Application
Registered**

Malaysia
Canada
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Switzerland

iSystem Foresight	Registered	United States of America
Javelin	Application	China
		European Union
		Japan
		Korea, Republic of (KR)
		Taiwan
		United States of America
	Published	Singapore
	Registered	International
KEYSTONE	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United States of America
KINEX	Application	European Union
		Korea, Republic of (KR)
		Singapore
	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United States of America
KODIAK	Registered	International
		Korea, Republic of (KR)
		Taiwan
		United States of America
LAVACOAT	Registered	United States of America
LDS	Allowed	United States of America

LDS	Application	China Korea, Republic of (KR) Taiwan
	Registered	European Union International Japan Singapore
LEAD	Registered	China European Union Germany (Federal Republic of) India International Japan Korea, Republic of (KR) Taiwan United Kingdom
Leopard	Allowed Application	United States of America Japan Korea, Republic of (KR) Taiwan
	Registered	European Union International
LIMITLESS EDGE	Allowed Registered	United States of America Benelux India International Singapore Sweden Switzerland United Kingdom
LINK	Registered	United States of America
Lion	Allowed Application	United States of America China Japan

Lion

Application

Korea, Republic of (KR)
Taiwan

Registered

European Union
International

Lucent

Application

China
European Union
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

Registered

International

Allowed

United States of America

Application

China
Japan
Korea, Republic of (KR)
Taiwan

Lynx

Registered

European Union
International
Singapore

Magnus

Application

China
European Union
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

Registered

International

MAKE POSSIBLE

Registered

European Union
Japan
Korea, Republic of (KR)
Malaysia
Singapore

MAKE POSSIBLE

Registered

United Kingdom
United States of America

MARANGONI

Registered

Austria
Benelux
China
France
Germany (Federal Republic of)
International
Italy
Japan
Liechtenstein
Monaco
Portugal
Spain
Switzerland

MARATHON

Registered

Korea, Republic of (KR)

MDLx

Registered

Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan

Mecatronix

Registered

United States of America
Germany (Federal Republic of)

Medeor

Application

China
European Union
Japan
Korea, Republic of (KR)

Medeor	Application	Malaysia Taiwan United States of America
	Published	Singapore
	Registered	International United Kingdom
MIRRA	Registered	China European Union Hong Kong India Indonesia Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
MIRRA (and Design)	Registered	European Union United Kingdom
MIRRA MESA	Registered	Korea, Republic of (KR) United States of America
ModuleTwin	Application	Korea, Republic of (KR) United States of America
	Registered	European Union International Japan
Momentum Fund	Application	Canada China India Israel Japan Korea, Republic of (KR) Malaysia

Momentum Fund	Application	Philippines Taiwan
	Published	United States of America
	Registered	European Union International Singapore United Kingdom
monitorMV	Registered	United Kingdom
monitorMV (and Design)	Registered	United Kingdom
Morpher	Allowed	United States of America
	Application	China Korea, Republic of (KR)
	Registered	European Union International Japan Singapore Taiwan
MUSTANG	Registered	United States of America
NEMA	Application	China Japan Taiwan
	Registered	European Union United States of America
NEOX	Registered	United States of America
NEPTUNE	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
Net Zero 2040 Playbook	Application	United States of America China European Union

Net Zero 2040 Playbook

Application

India
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan

NetConnect

Allowed Application

United States of America
United States of America
China
Israel
Japan
Korea, Republic of (KR)
Taiwan

Registered

European Union
International
Singapore

NEW ARISTO

Registered

China
European Union
Germany (Federal Republic of)
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom

NEW ARISTO (in Chinese characters)

Registered

China

NEXUS-E

Registered

China
European Union
Germany (Federal Republic of)
India
Indonesia
International
Japan
Korea, Republic of (KR)
United Kingdom

NEXUS-E	Registered	United States of America
NOKOTA	Registered	United States of America
NUCLEON	Allowed	United States of America
	Application	China
	Registered	European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
NutriAPC	Registered	United Kingdom
NutriMV	Registered	China
		International
		Singapore
		United Kingdom
		United States of America
OLYMPIA	Registered	European Union
		International
		Taiwan
		United Kingdom
		United States of America
ONYX	Registered	United States of America
OPTA	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United States of America
OPTIKON	Registered	United Kingdom
OPTIVA	Registered	United States of America
OPTOPLEX	Registered	Benelux
		China

OPTOPLEX	Registered	France Germany (Federal Republic of) International Italy Switzerland Taiwan United Kingdom
Palisade	Allowed Application Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
PALOMAR	Registered	United Kingdom
PAT-NAV Pat-Nav PatNav Pat Nav PAT NAV	Registered	United Kingdom
PERCEPTIVE ENGINEERING	Registered	Singapore United Kingdom
Perceptive Engineering	Registered	United Kingdom
PerceptiveAPC	Registered	China International Singapore United Kingdom United States of America
PerformAPC	Registered	United Kingdom
PerformMV	Registered	United Kingdom
PharmaAPC	Registered	United Kingdom
PharmaMV	Registered	China International Singapore United Kingdom United States of America
PharmaNeuron	Registered	United Kingdom

PharmaVision	Application	United States of America
PICOSUN	Registered	International
PICOSUN (in Katakana characters)	Registered	United States of America
PIKA	Registered	Japan
	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United States of America
PIONEER	Application	Japan
	Published	Malaysia
	Registered	China
		European Union
		International
		Israel
		Korea, Republic of (KR)
		Singapore
		Switzerland
		Taiwan
		United Kingdom
		United States of America
PISCES	Application	United Kingdom
PIVOT	Registered	China
		Germany (Federal Republic of)
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
PiVot “樞紐” (Chinese translation of the meaning of PiVot)	Registered	Taiwan
PiVot ”樞紐” (Chinese translation of the meaning of PiVot)	Registered	China
Pixel Blending	Application	China

Pixel Blending	Application	Japan Korea, Republic of (KR) Taiwan United States of America
	Registered	European Union International
POLARIS	Application	Japan
	Registered	European Union International Israel Korea, Republic of (KR) Singapore Taiwan United States of America
PRECISION	Application	China
	Registered	China International Japan Taiwan United States of America
PRECISION 5000	Registered	Benelux France Hong Kong Indonesia Ireland (Republic of) Israel Italy Singapore Spain Switzerland Taiwan United States of America
PRECISION CVD	Registered	China
Premus	Application	China

Premus	Application	European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PRESIDIO	Registered Registered	International Canada China European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
PRESTO	Registered	China
PRIME	Application Registered	United States of America International Singapore
PRIMEVISION	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
PRISTINE	Registered	China International Japan

PRISTINE	Registered	Korea, Republic of (KR) Taiwan
PRIZM	Registered	United States of America
PROAnalytics	Application	United States of America China European Union Israel Japan Korea, Republic of (KR) United States of America
ProcessTwin	Registered	International
	Application	Singapore Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore
PRODUCER	Registered	European Union Japan Taiwan United Kingdom United States of America
PRODUCER KODIAK	Registered	China
PRODUCER NANOCURE	Registered	China
PRODUCER ONYX	Registered	China Japan Korea, Republic of (KR) Taiwan
PRODUCER XP PRECISION	Registered	United States of America China
PROMIS	Registered	Korea, Republic of (KR) United States of America
PROMOTO	Registered	International

PROMOTO	Registered	Korea, Republic of (KR) Taiwan
Pronto	Registered	United States of America China International Japan Korea, Republic of (KR) Taiwan
PROVISION	Registered	United States of America China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom
pSynapse	Registered	United States of America United Kingdom
PURITY	Registered	Japan Korea, Republic of (KR) Taiwan
PYRA	Registered	United States of America China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
QbDD	Registered	United States of America United Kingdom
QUICKSTART	Registered	China European Union

QUICKSTART	Registered	International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
RADIANCE	Application Registered	European Union China European Union International Japan Switzerland United Kingdom United States of America
RADION	Published Registered	China United States of America
RAIDER	Registered	European Union United Kingdom United States of America
RAPTOR	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
REFLEXION	Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America

RETICLEAN	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
RETIGUARD	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Reveal	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
ROSSA	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
RT Manager	Registered	International Singapore United Kingdom United States of America
SACVD	Registered	Japan United States of America

SAFARI

**Allowed
Registered**

United States of America
European Union
International
Korea, Republic of (KR)
Singapore
Taiwan

Sana

**Allowed
Registered**

United States of America
China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan

SANSA

**Application
Registered**

Korea, Republic of (KR)
Taiwan
China
Korea, Republic of (KR)
United States of America

SAPHIRA

**Application
Registered**

Malaysia
China
International
Japan
Korea, Republic of (KR)
Taiwan

SCULPTA

**Application
Registered**

United States of America
China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

SELECTRA

**Application
Registered**

China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United Kingdom
United States of America

SELFI

**Application
Registered**

China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

SemiGuru

**Allowed
Application**

European Union
China
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

SEMITOOL

**Registered
Registered**

International
Benelux
Canada
China
European Union
Ireland (Republic of)
Japan
Korea, Republic of (KR)

SEMITOOL	Registered	Singapore United Kingdom United States of America
SEMVision	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
SICONI	Registered	United States of America
SideView	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore United States of America
SIGMAMELTEC (Word)	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
SIGNET	Allowed Application	United States of America Canada Korea, Republic of (KR) Switzerland
	Published	Israel

SIGNET

Registered

Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan

SILENA

Registered

China
European Union
International
Israel
Korea, Republic of (KR)
Malaysia
Singapore
Taiwan
United Kingdom

SILVIA

Registered

United States of America

SINGEN & DESIGN

Registered

United States of America

SIP ENCORE

Registered

United States of America

SIXTHSENSE

Application

Korea, Republic of (KR)
Taiwan

Registered

China
Korea, Republic of (KR)

SLD

Allowed

United States of America

Application

Korea, Republic of (KR)

Registered

European Union
International
Japan
Singapore

SLD	Registered	Taiwan
SMARTFACTORY	Registered	United States of America
SMARTFACTORY RX	Registered	European Union International Japan Singapore United Kingdom United States of America
SMARTSCHEd	Registered	United States of America
SMARTSTART	Published Registered	Japan Korea, Republic of (KR) United States of America
SmartWeb	Registered	Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Taiwan United Kingdom
SOFT LINE (Chinese Characters)	Registered	China
SOFT LINE (in Chinese characters)	Registered	China European Union
SOFT LINE (Latin characters)	Registered	China
SOLION	Registered	China Japan Taiwan United States of America
SONETTO	Registered	China
SPC3D	Application Registered	China European Union International

SPC3D	Registered	Japan Singapore United States of America
Sprinter	Allowed Application	United States of America China Japan Korea, Republic of (KR)
	Registered	European Union International Singapore Taiwan
STARK	Application Registered	China International Korea, Republic of (KR) Taiwan
STATIONWORKS	Registered	United States of America
STELLA	Registered	European Union International Korea, Republic of (KR) Singapore Taiwan
		United States of America
STENSAR	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SuperScan	Application Registered	China European Union International Japan

SuperScan	Registered	Korea, Republic of (KR) Singapore
SYM3	Registered	United States of America China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Sym3 Y Magnum	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
SYM3D	Registered Registered	International China Japan Korea, Republic of (KR) Taiwan United States of America
SYNEXIS	Registered	United Kingdom
TANGO	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
	Registered	China European Union Singapore

TANGO TANGO SYSTEMS	Registered Application	United States of America International Japan Korea, Republic of (KR) Malaysia Taiwan
	Published Registered	United States of America China European Union Singapore
TARGA	Registered	China International Korea, Republic of (KR) Taiwan United States of America
Technology & Value SIGMAMELTEC (and Design)	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Technology Enabled Services	Application Registered	China International Japan United States of America
TEMPO	Registered	China European Union Taiwan United Kingdom
TERSA	Registered	China European Union International

TERSA	Registered	Korea, Republic of (KR) Taiwan United Kingdom United States of America
Tesseract	Registered	International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
TETRA	Registered	China European Union International Japan Singapore Taiwan United States of America
THERMION	Application Registered	China China International Korea, Republic of (KR) United States of America
THINK SILICON	Registered	United States of America
Tiburon	Allowed Application	United States of America China Japan Singapore Taiwan
	Registered	European Union International Korea, Republic of (KR)
TKM	Registered	United States of America
TKM TOTAL KIT MANAGEMENT	Registered	Taiwan
ToolTwin	Application	Korea, Republic of (KR)

ToolTwin	Application Registered	United States of America European Union International Japan Singapore
TOPAZ	Registered	China International Japan Korea, Republic of (KR) Taiwan
TOPBEAM	Registered	United States of America Benelux China France Germany (Federal Republic of) International Italy Japan Spain United Kingdom
TOPCOIL	Registered	United States of America China Italy Japan Korea, Republic of (KR) Latvia Taiwan
TopMet	Registered	China Germany (Federal Republic of) International Italy Spain United Kingdom
TOTAL KIT MANAGEMENT	Registered	United States of America

TotalConnect	Allowed Application Published Registered	United States of America China Israel European Union International Japan Korea, Republic of (KR) Singapore Taiwan
TreatMag	Registered	Germany (Federal Republic of)
TRIDENT	Registered	Taiwan
TRILLIUM	Registered	Korea, Republic of (KR) Taiwan
Tripoli	Application Registered	United States of America China Korea, Republic of (KR) European Union International Japan Singapore Taiwan
TrueTarget	Allowed Application Registered	United States of America United States of America Israel Korea, Republic of (KR) China European Union International Japan Singapore Taiwan
TruFilm	Registered	United Kingdom
TruShape	Allowed Application	United States of America International

TruShape	Registered	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
TWIN CHAMBER	Registered	United States of America
Twin-AF-Mag	Registered	Benelux China Czechia Finland France Germany (Federal Republic of) Hungary India International Italy Japan Korea, Republic of (KR) Liechtenstein Poland Portugal Spain Sweden Switzerland Taiwan Turkey United Kingdom
TXZ	Registered	Korea, Republic of (KR) United States of America
ULTIMA HDP CVD	Registered	Japan Korea, Republic of (KR) United States of America

UniConnect	Allowed Application	United States of America China Japan Korea, Republic of (KR)
	Registered	European Union International Israel Singapore Taiwan
UVISION	Registered	United States of America
VALAYA	Allowed	United States of America
	Published	India
	Registered	Benelux International Singapore Sweden Switzerland United Kingdom
Valaya Design Mark	Allowed	United States of America
	Registered	Benelux India International Singapore Sweden Switzerland United Kingdom
VALAYA LIMITLESS EDGE (and Design)	Allowed Application	United States of America
	Registered	India Benelux International Singapore Sweden Switzerland United Kingdom

VANTAGE	Registered	United States of America
VANTAGE RADIANCE	Registered	China Korea, Republic of (KR) Taiwan
VANTAGE VULCAN	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
VARIAN	Registered	China
VARIAN CONTROL SYSTEM	Registered	United States of America
VARIAN POSITIONING SYSTEM	Registered	United States of America
VCS	Registered	China
VECTRA IMP SOURCE	Registered	United States of America
VENTARA	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
VERA	Application Registered	Japan China European Union International Israel Taiwan United States of America
Veranome Biosystems	Registered	United Kingdom
VERICELL	Registered	United States of America
Veridian	Allowed Application	United States of America China European Union Japan

Veridian	Application	Korea, Republic of (KR) Taiwan
VERITYSEM	Published	Singapore
VERSITA	Registered	International
	Registered	United States of America
	Allowed	United States of America
	Application	China
	Registered	European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
VIISION	Registered	European Union
		Japan
		Korea, Republic of (KR)
		Taiwan
		United Kingdom
		United States of America
VIISTA	Registered	China
		European Union
		Japan
		Korea, Republic of (KR)
		Taiwan
		United Kingdom
		United States of America
Vistara	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United States of America
VITA	Registered	China

VITA	Registered	European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
VIVA	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
vMask	Registered	United States of America
VOLARIS	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
VOLO FLOOD	Registered	China Taiwan
VOLO NEST	Registered	China Taiwan
VOLO PRINT	Registered	China Taiwan
VOLTA	Registered	China International Japan Korea, Republic of (KR) Taiwan

VOLTA	Registered	United States of America
VSEA	Registered	China
WaterAPC	Registered	United Kingdom
WaterMV	Registered	China International Singapore United Kingdom United States of America
WaterNeuron	Registered	United Kingdom
WIZER	Registered	United States of America
WORKSTREAM	Registered	China European Union International Japan United Kingdom United States of America
Xact	Application	China European Union Korea, Republic of (KR) Taiwan
	Published	Israel Singapore
	Registered	United States of America International Japan
Xsite	Application	Japan Korea, Republic of (KR)
	Registered	European Union International Singapore Taiwan United Kingdom
ZEPHYR	Allowed	United States of America United States of America

ZEPHYR

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

各美讲堂 - Individual Beauty

Registered

應用材料.tw

Registered

China
Taiwan

Update Date: October 8, 2024